

Electronic Supplementary Information

Table S1. Chemical structures of FQs being used as model organic pollutant

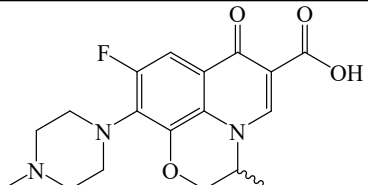
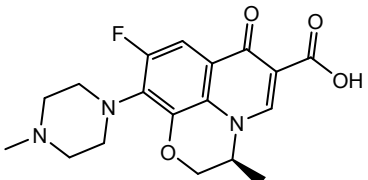
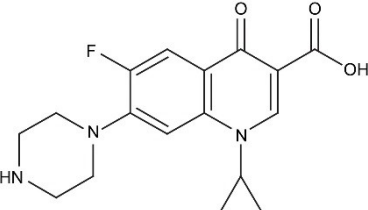
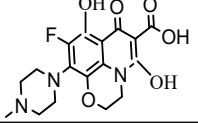
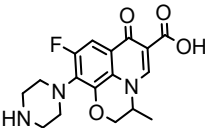
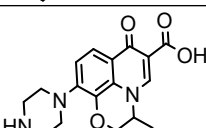
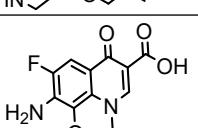
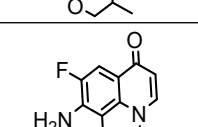
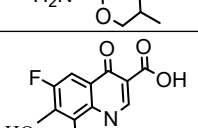
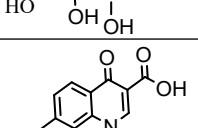
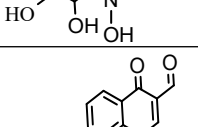
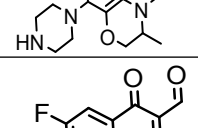
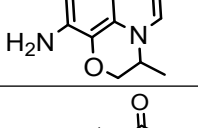
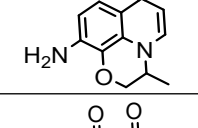
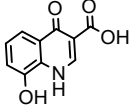
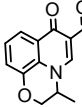
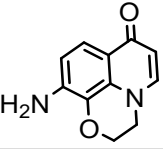
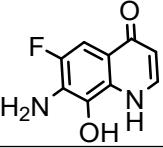
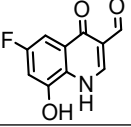
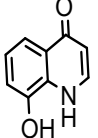
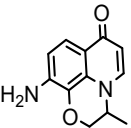
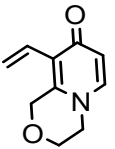
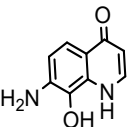
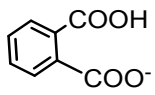
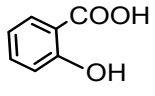
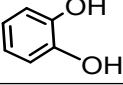
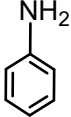
FQs	Structure	λ_{\max} (nm)	MW (g/mol)	Solubility (g/L)	pKa	Existing
Ofloxacin (OFX)		291	361.36	10.8	pKa ₁ =6.1; pKa ₂ =8.28	OFX ⁺ , OFX ⁻ OFX ^{Zwitterion}
Levofloxacin (LFX)		297	361.36	1.5	pKa ₁ =6.24; pKa ₂ =8.74	LFX ⁺ , LFX ⁻ LFX ^{Zwitterion}
Ciprofloxacin (CFX)		278	331.35	1,0	pKa ₁ =6.09; pKa ₂ =8.62	CFX ⁺ , CFX ⁻ CFX ^{Zwitterion}

Table S2. Intermediate product of ofloxacin in BIZ/Na₂S₂O₈/Vis system identified by LC-ESI-QTOF-MS

Compound	m/z	Molecular formula	Molecular structure Retention time
M ₁	393	C ₁₈ H ₂₀ FN ₃ O ₆	
M ₂	347	C ₁₇ H ₁₈ FN ₃ O ₄	
M ₃	329	C ₁₇ H ₁₉ N ₃ O ₄	
M ₄	277	C ₁₃ H ₁₀ FN ₂ O ₄	
M ₅	231	C ₁₂ H ₁₁ FN ₂ O ₂	
M ₆	256	C ₁₀ H ₇ FO ₆	
M ₇	238	C ₁₀ H ₈ NO ₆	
M ₈	312	C ₁₇ H ₁₈ N ₃ O ₃	
M ₉	261	C ₁₃ H ₁₀ FN ₂ O ₃	
M ₁₀	212	C ₁₂ H ₁₁ N ₂ O ₂	
M ₁₁	224	C ₁₀ H ₆ FO ₄	

M ₁₂	206	C ₁₀ H ₇ NO ₄	
M ₁₃	234	C ₁₂ H ₁₁ FN ₂ O ₂	
M ₁₄	198	C ₉ H ₇ FN ₂ O ₂	
M ₁₅	194	C ₉ H ₇ FN ₂ O ₂	
M ₁₆	208	C ₁₀ H ₆ FNO ₃	
M ₁₇	161	C ₉ H ₇ NO ₂	
M ₁₈	216	C ₁₂ H ₁₂ N ₂ O ₂	
M ₁₉	177	C ₁₂ H ₁₂ N ₂ O ₂	
M ₂₀	176	C ₉ H ₈ N ₂ O ₂	
M ₂₁	165	C ₈ H ₅ O ₄ ⁻	
M ₂₂	137	C ₇ H ₆ O ₃	
M ₂₃	110	C ₆ H ₆ O ₂	

M ₂₄	93	C ₆ H ₇ N	
M ₂₅	116	C ₄ H ₄ O ₄	HOOCCH=CHCOOH
M ₂₆	90	C ₂ H ₂ O ₄	HOOC-COOH
M ₂₇	86	C ₄ H ₆ O ₂	CH ₂ =CHCH ₂ COOH
M ₂₈	84	C ₄ H ₄ O ₂	CH≡CCH ₂ COOH
M ₂₉	70	C ₄ H ₆ O	CH ₂ =CHCH ₂ CHO
M ₃₀	68	C ₄ H ₄ O	CH≡CCH ₂ CHO
M ₃₁	56	C ₃ H ₄ O	CH ₂ =CHCHO

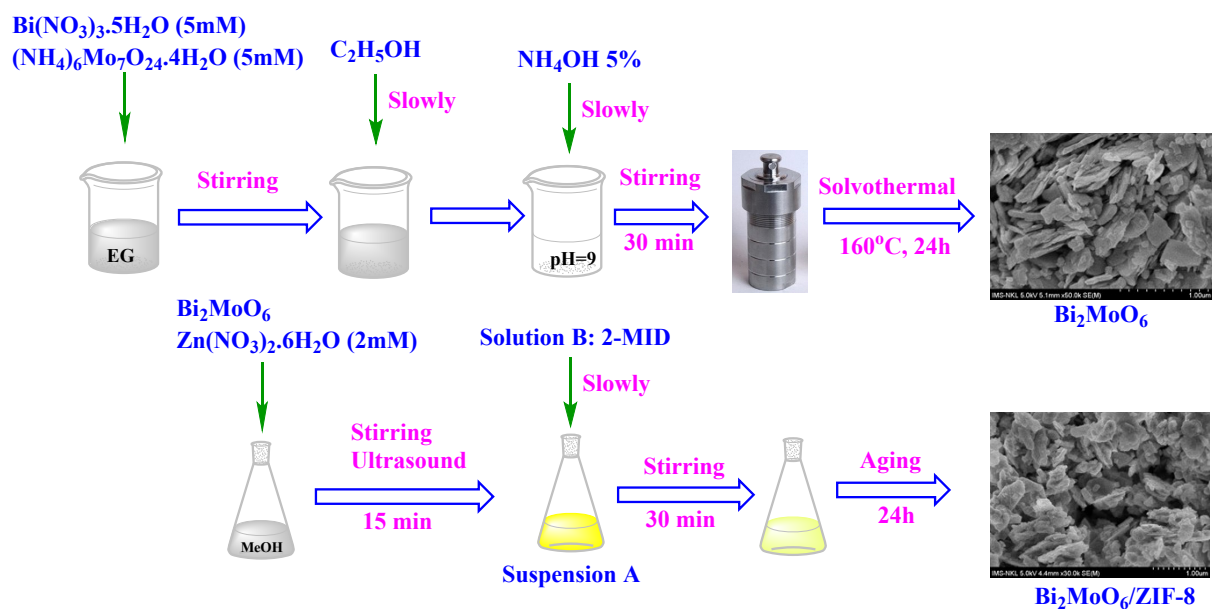


Figure S1. Procedure for synthesis of BIZ heterojunction

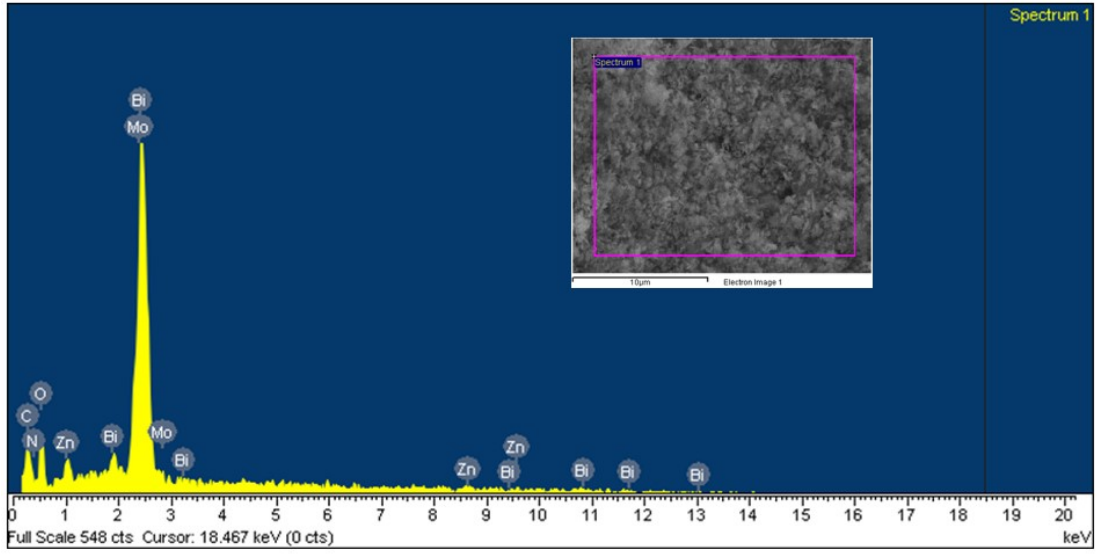


Figure S2. The EDX result of the BIZ heterojunction

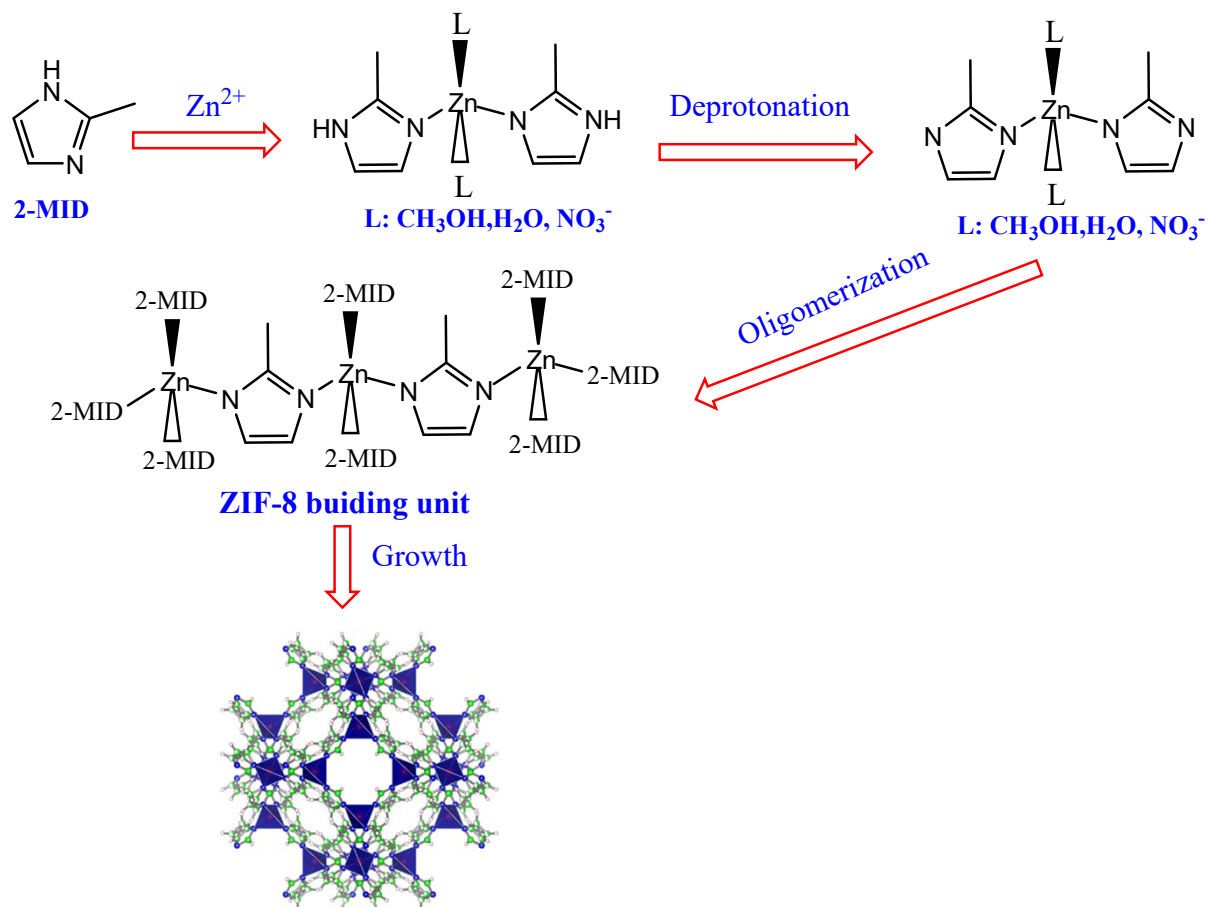


Figure S3. Proposed mechanism for the formation of ZIF-8 material

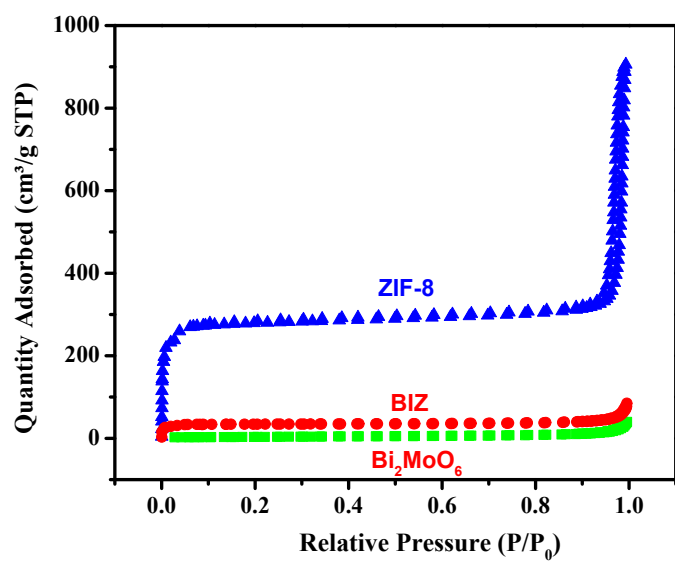


Figure S4. The N₂ adsorption-desorption isotherms of Bi₂MoO₆, ZIF-8, and BIZ materials

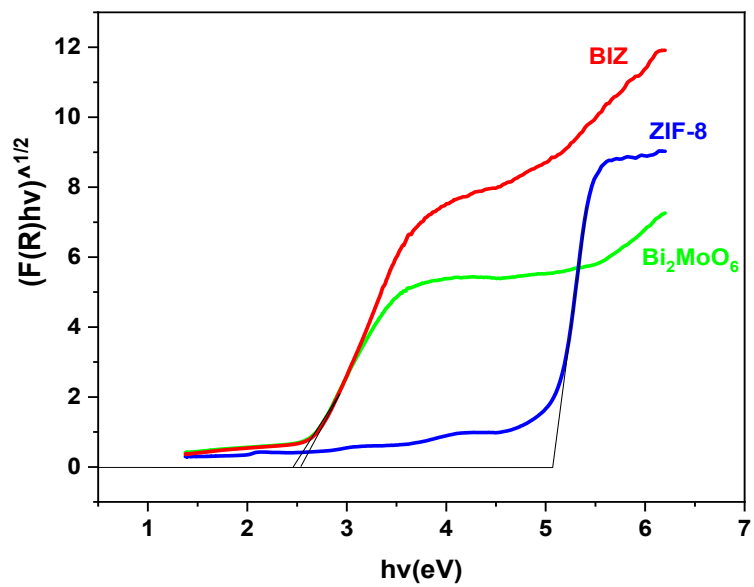
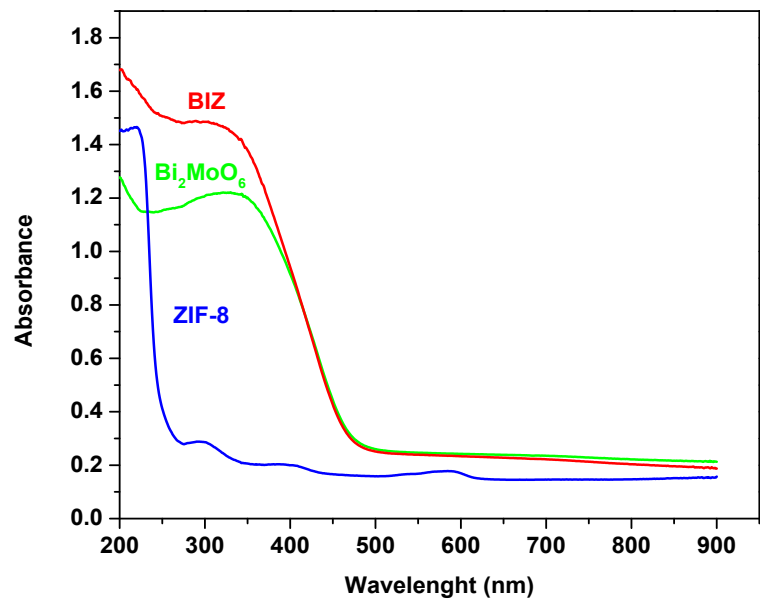


Figure S5. UV-Vis DRS spectra of Bi₂MoO₆, ZIF-8, and BIZ materials

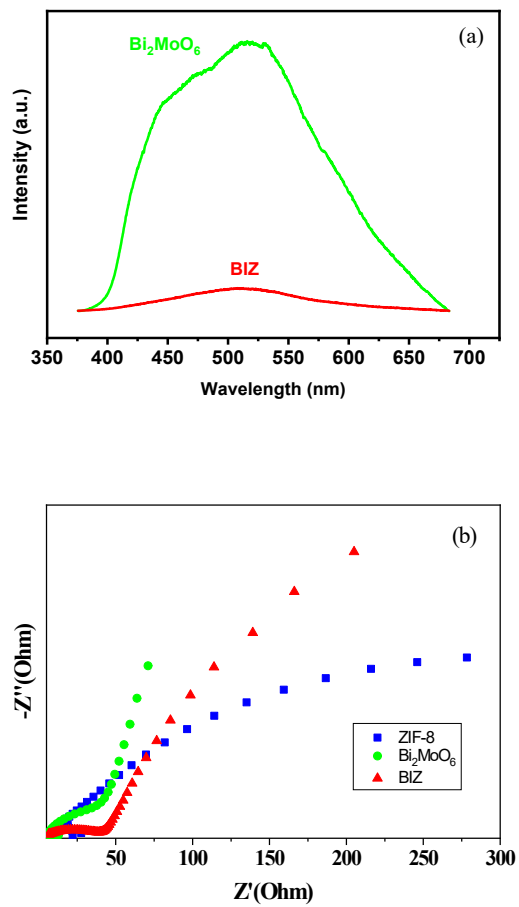


Figure S6. (a) PL spectra of pure Bi_2MoO_6 and BIZ heterojunction, and (b) EIS Nyquist plots of ZIF-8, Bi_2MoO_6 , and BIZ

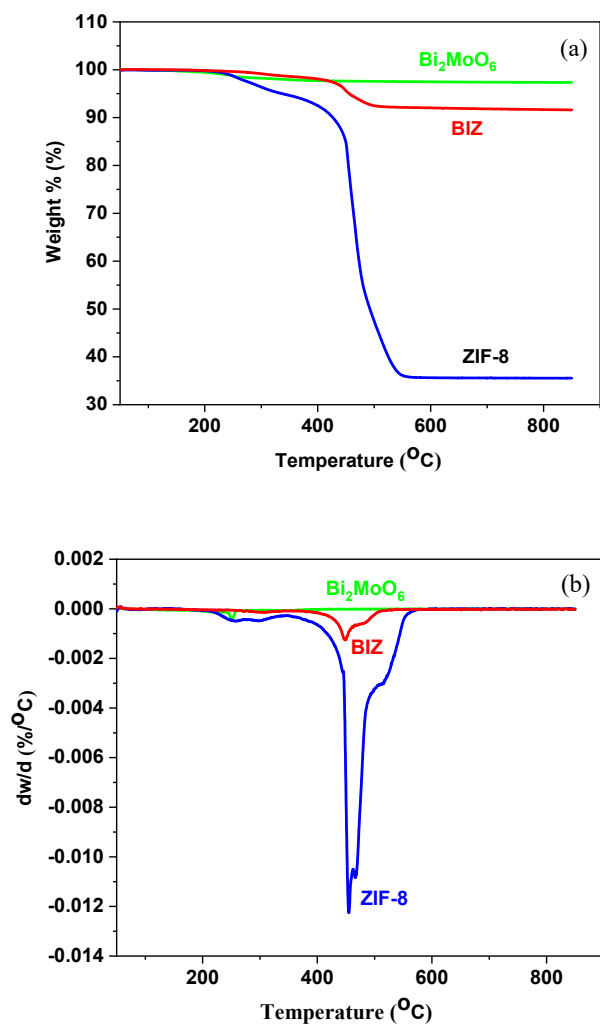


Figure S7. (a) TG and (b) DTG results of Bi₂MoO₆, ZIF-8, and BIZ materials

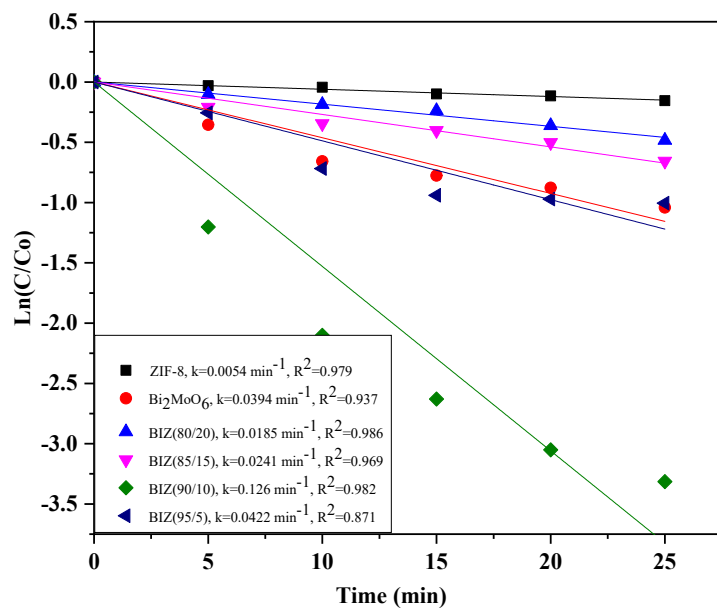


Figure S8. Photocatalytic decomposition rates of OFX by different BIZ materials (n = 3)

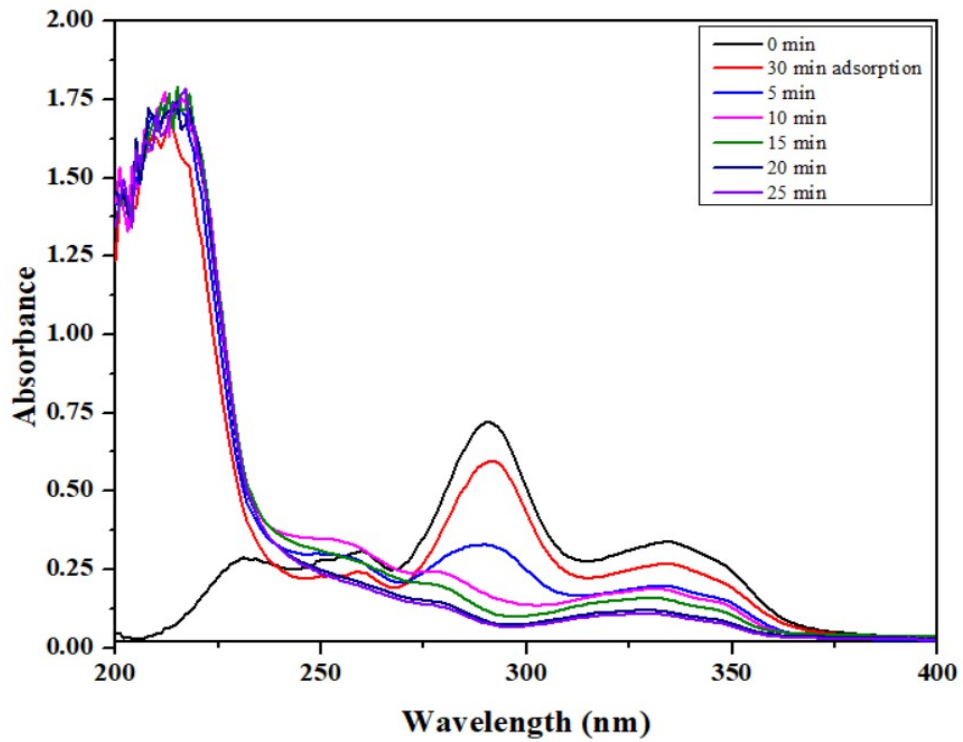
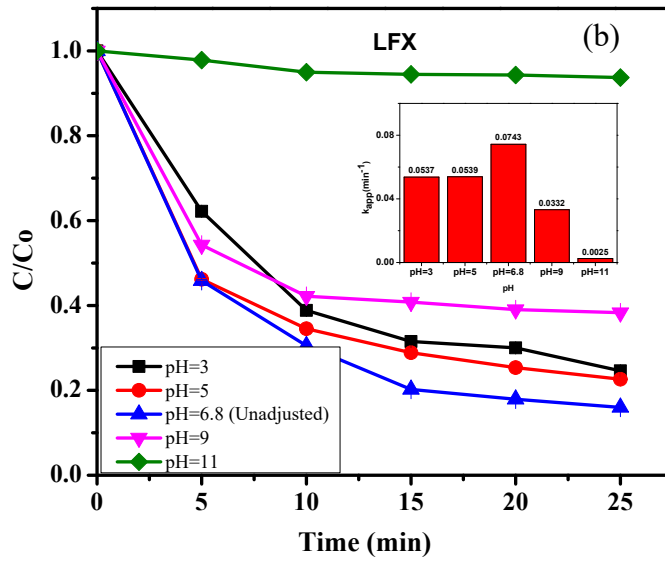
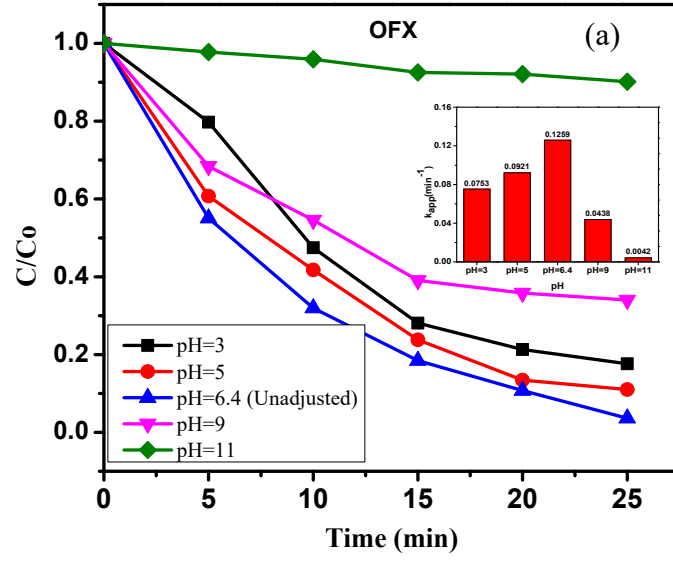


Figure S9. UV-Vis spectra of OFX during 30 min of adsorption and then 25 min of photocatalysis



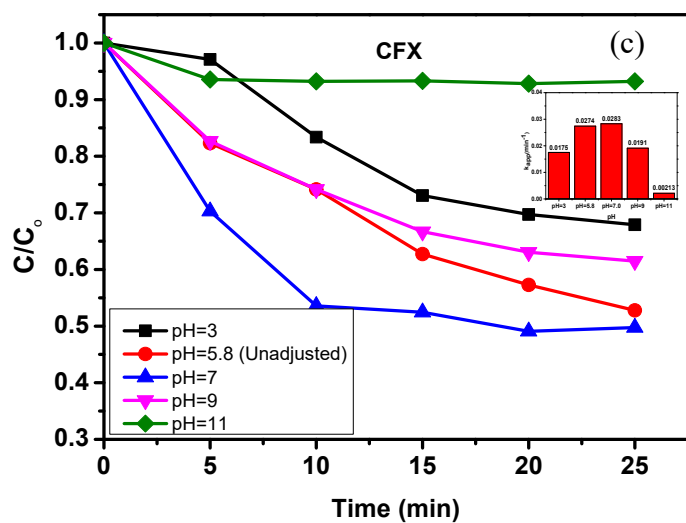


Figure S10. Effects of initial pH on the photocatalytic removal efficiency of (a) OFX, (b) LFX, and (c) CFX (Insets are the pseudo-first-order reaction rate constants at different pH)

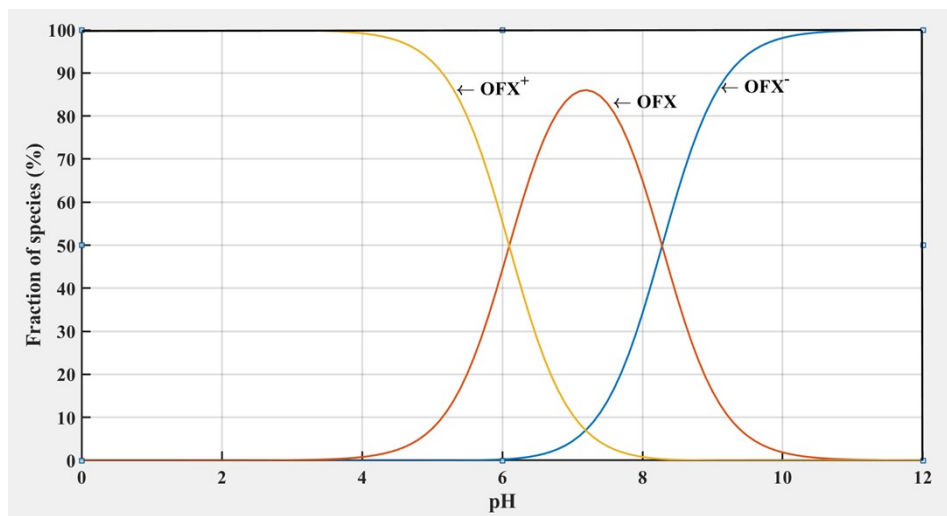
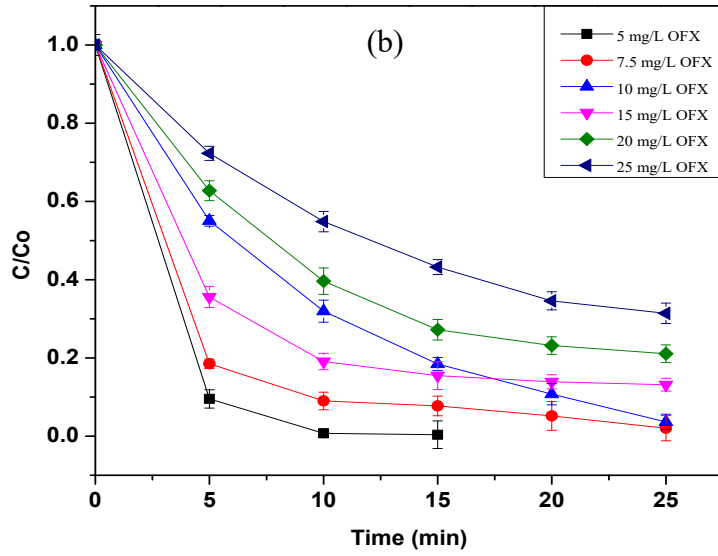
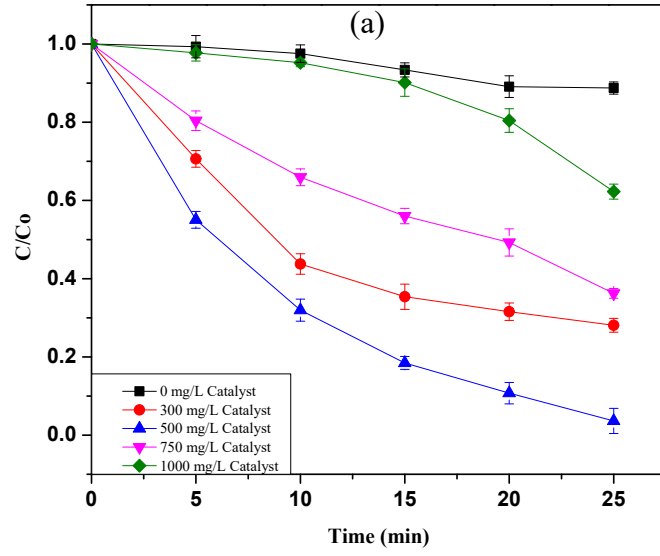


Figure S11. Specification of ofloxacin as a function of pH value in aqueous solution



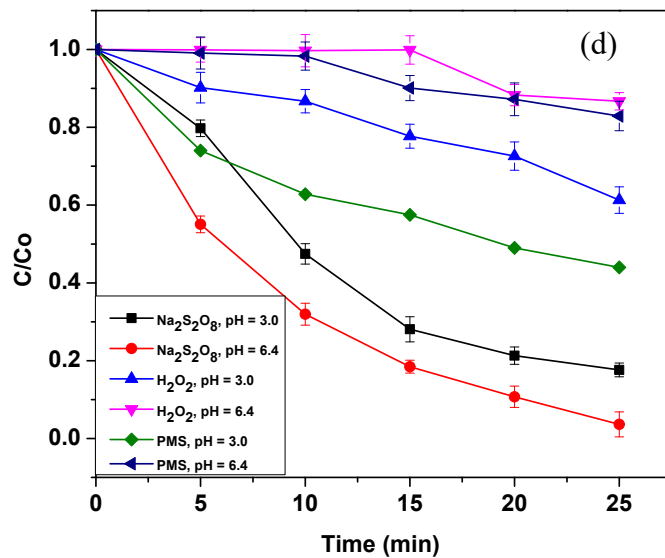
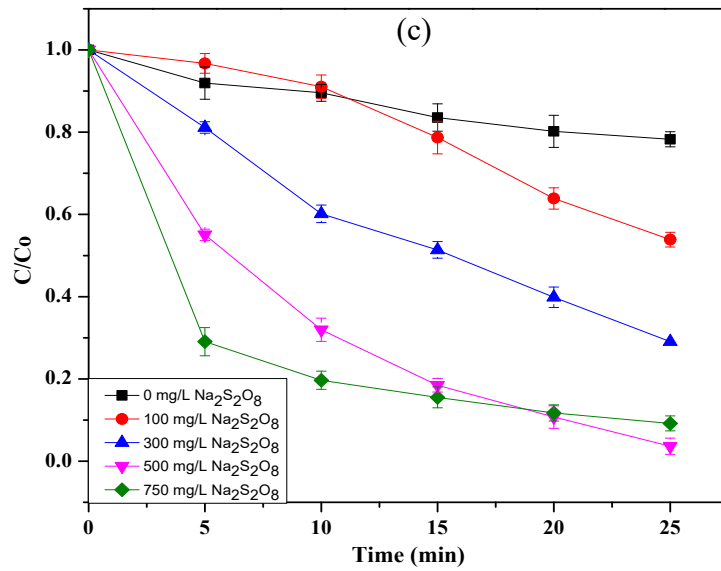


Figure S12. Effects of (a) photocatalyst dosage, (b) OFX concentration, (c) $\text{Na}_2\text{S}_2\text{O}_8$ concentration, and (d) oxidant on the photocatalytic removal efficiency of OFX (n = 3)

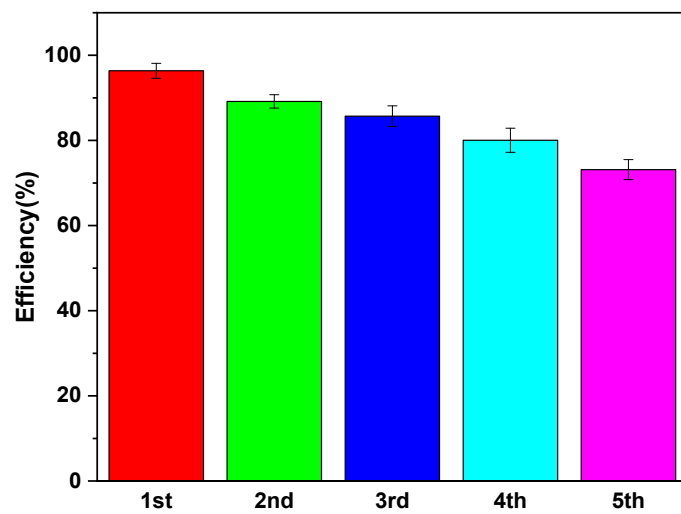


Figure S13. The degradation of OFX after 5 cycles of the photocatalytic experiment (n = 3)

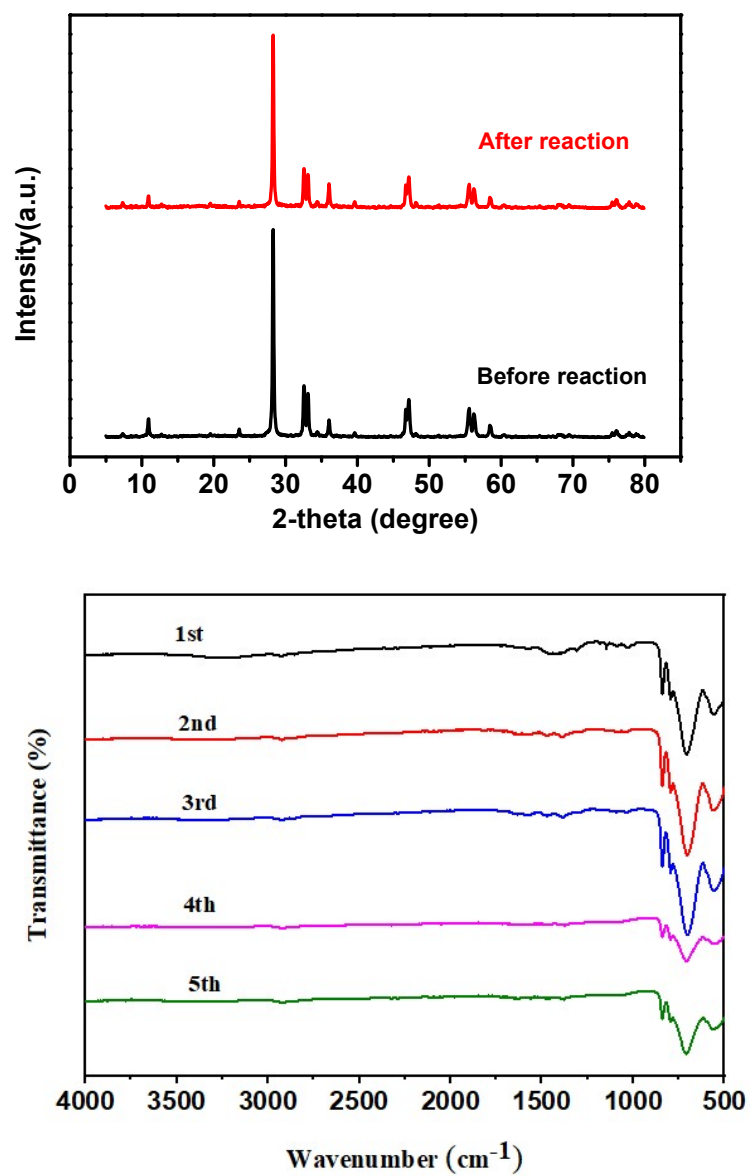


Figure S14. (a) XRD patterns of the BIZ material before and after five cycles of experiment and (b) FTIR spectra of BIZ material after each cycles of experiment

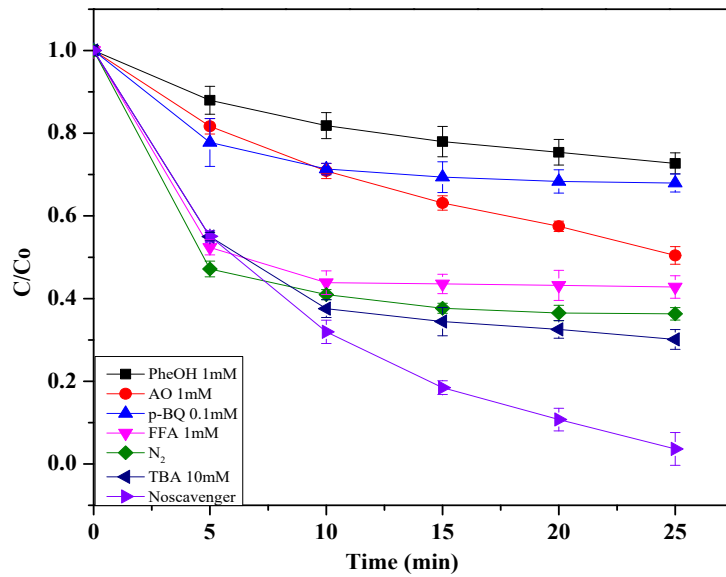


Figure S15. Effect of scavengers on the photocatalytic removal efficiency of OFX (n = 3)

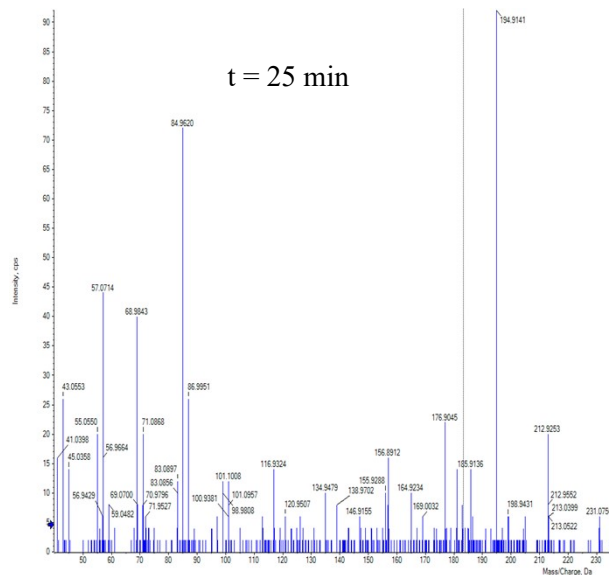
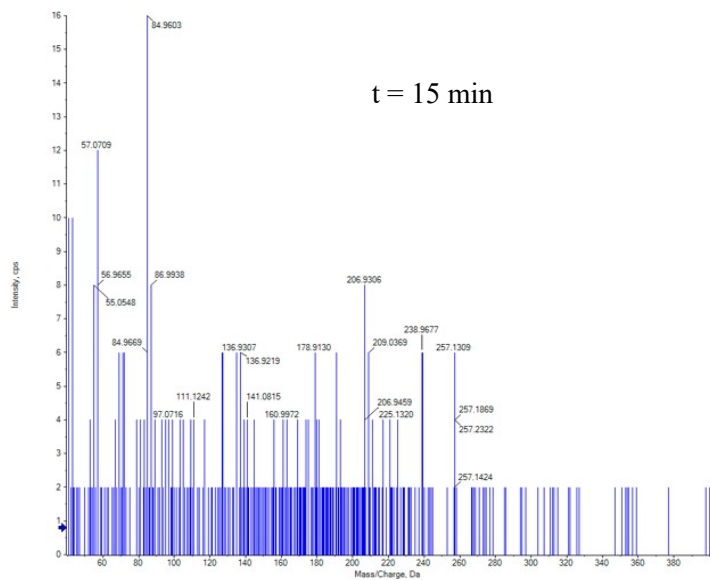
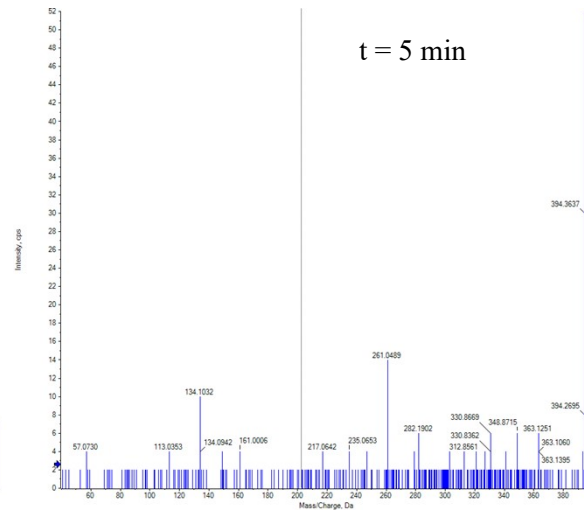
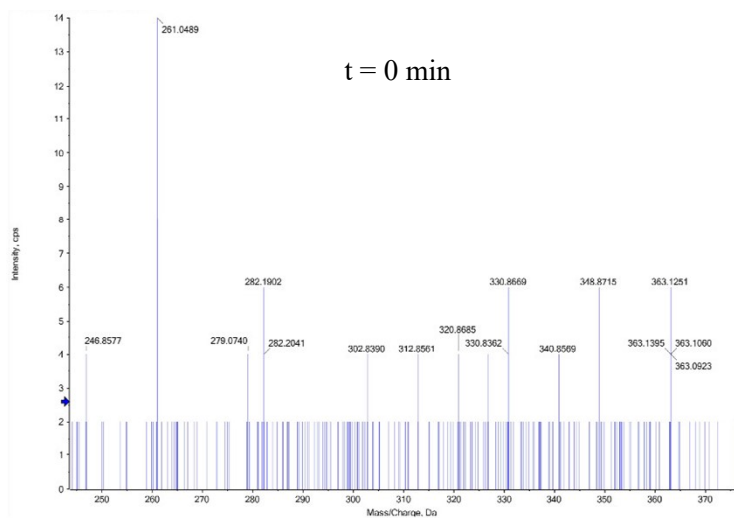


Figure S16. MS results of OFX solution during the reaction time